EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4	"2002037506"	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:25
L2	1	2002-426843.NRAN.	DERWENT	ADJ	ON	2009/08/12 16:25
L3	4120	(anodi$6) with (silicon or Si) with (substrate or support or etch)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:29
L4	8859	anode with (porous or pore or porosity) with (film or coat or coating or layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:29
L5	8257	cathode with (porous or pore or porosity) with (film or coat or coating or layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:29
L6	15813	electrolyte with (porous or pore or porosity) with (film or coat or coating or layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:29
L7	2064	L4 with L5 with L6	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:29

L8	3	L7 with 3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:29
L9	5	L7 same 3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:30
L10	2	9 not 8	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:30
L11	17	L7 and 3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:31
L12	7	11 and fuel cell	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:32
L13	7	12 not 9	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:32
S14	8859	anode with (porous or pore or porosity) with (film or coat or coating or layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:30
S15	8257	cathode with (porous or pore or porosity) with (film or coat or coating or layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:30

S16	15813	electrolyte with (porous or pore or porosity) with (film or coat or coating or layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:30
S17	2064	S14 with S15 with S16	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:30
S18	2	S17 with (etch or etch$3) with (silicon or Si) with (substrate or support or etch)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:31
S19	47	S17 and (etch or etch$3) with (silicon or Si) with (substrate or support or etch)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:31
S20	51	S17 and (etch or etch$3) same (silicon or Si) with (substrate or support or etch)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:31
S21	34	S17 and (etch or etch$3) with (silicon or Si) with (substrate or support or base)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:31
S22	2	S17 with (etch or etch$3) with (silicon or Si) with (substrate or support or base)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 13:31

EAST Search History (Interference)

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